

Contents

	Page
Abstract	iii
Acknowledgements	v
Contents	vii
List of Figures	xi
List of Tables	xv
List of Symbols	xvii
List of Abbreviations	xix
Chapter 1: Introduction	
1.1 Motivation and Objectives	2
1.2 Organization of Thesis	3
1.3 List of Publications	
1.3.1 Peer Reviewed Journal Publications	6
1.3.2 Conference Paper	6
Chapter 2: Literature Review	
2.1 Introduction	7
2.2 Tunable Device Technologies	8
2.2.1 Micro-electro-mechanical systems, (MEMS)	8
2.2.2 Semiconductors	9
2.2.3 Dielectric Materials	9
2.3 Frequency Dispersion in Dielectrics	11
2.3.1 Atomic polarization	12
2.3.2 Electronic polarization	12
2.3.3 Dipolar polarization	12
2.4 Dielectric Constant and Polarization	12
2.4.1 Classification of Dielectrics	12
2.5 Soft Mode Concept and Tunability	15
2.6 Perovskite Oxides Films for Tunable Applications	17
2.6.1 Barium Strontium Titanate Crystal Structure	18
2.6.2 BST Thin Film for Tunable Application	19
2.6.3 Lead Zirconate Titanate structure	20
2.6.4 PZT Thin Film for Tunable Application	21
2.7 High Energy Radiation Environments	23
2.7.1 Radiation in Space	23
2.7.2 Radiation in Nuclear Reactors	23
2.7.3 Weapons Environment for Military use	24
2.7.4 Radiation Processing Environments	24
2.8 Interaction of Radiation with Matter	24
2.8.1 Gamma Radiation	24
2.8.1.1 Photo-Electric Effect	24
2.8.1.2 Compton Scattering	25
2.9.1.3 Pair Production	26
2.8.2 Neutron Radiation	26
2.9 Radiation Dose	26
2.10 High Energy Radiation Effects	27
2.10.1 Point Defects	28
2.10.2 Microstructural Defects	29
2.11 Radiation Effects on Electronic Devices	30
2.11.1 High Energy Radiation Effects on Perovskite Oxides	31
Chapter 3: Experimental Techniques	
3.1 Introduction	33
3.2 Thin Film Deposition Techniques	36

3.2.1	RF Magnetron Sputtering	36
3.2.2	Pulsed Laser Deposition	39
3.2.3	Thermal Evaporation	40
3.3	X-Ray Diffraction	41
3.4	Atomic Force Microscope	43
3.5	X-Ray Photoelectron Spectroscopy	44
3.6	UV-VIS-NIR Spectrophotometer	46
3.7	Perovskite Thin Films for Microwave Circuit Applications	47
	3.7.1 Interdigitated Capacitor (IDC)	47
	3.8.2 Parallel Plate Capacitor	48
3.9	Electrical Characterisation	48
3.10	High Energy Irradiation	49
	3.10.1 Gamma Irradiation	49
	3.10.2 Neutron Irradiation	50

Chapter 4: Effect of Gamma Irradiation on Structural and Surface Chemical Properties of BaSrTiO₃ Thin Film

4.1	Introduction	51
4.2	Optimisation of Deposition Parameters for BST Thin Films	51
	4.2.1 Structural Analysis of Sputtered BST Films	53
	4.2.2 Surface Morphology of BST Films	54
	4.2.3 X-Ray Photoelectron Spectroscopy measurement	55
	4.2.4 Optical Characterization of Pristine BST Thin Film	57
	4.2.5. Dielectric Properties	58
4.3	Gamma Irradiation Induced Effects on BST Films	59
	4.3.1 Structural Analysis of Gamma Irradiated BST	59
	4.3.2 Surface Morphological Study	60
	4.3.3 Core Level and Valance Band Photoelectron Spectroscopy	61
	4.3.4 Optical Properties of Irradiated BST film	66
	4.3.5 Leakage Current Study	66
4.4.	Conclusions	67

Chapter 5: Gamma Radiation Induced Electrical Response of BaSrTiO₃ Interdigitated Capacitor

5.1	Introduction	69
5.2	Deposition of BST on Sapphire Substrate	70
	5.2.1 Electrode Patterning on BST	71
5.3	Structural and Surface Morphological Characterizations	72
5.4	Electrical Characterization	74
	5.4.1 Capacitance – Voltage (C-V) Measurements	74
	5.4.2 Current - Voltage (I-V) Measurements	78
5.5	Conclusions	80

Chapter 6: Neutron Induced Structural and Electrical Response of BaSrTiO₃ Interdigitated Capacitor

6.1	Introduction	81
6.2	Experimental Details	82
	6.2.1 Sample Preparation	82
	6.2.2 Neutron Irradiation	82
6.3	Structural and Surface Morphological Study	83
6.4	Electrical Characterization	85
	6.4.1 Capacitance – Voltage (C-V) Measurements	85
	6.4.2 Leakage Current Study	87
6.5	Conclusions	88

Chapter 7: Gamma Radiation Induced Structural and Surface Chemical Changes in PbZrTiO₃ Thin Film

7.1	Introduction	89
7.2	PLD Grown Epitaxial PZT Thin Film	90
7.3	Structural Analysis of PZT/SRO/STO Thin Film	91
7.4	Surface Morphological Study	93
7.5	X-Ray Photoelectron Spectroscopic on PZT	93

7.5	Leakage Current Analysis	98
7.6	Conclusions	99
Chapter 8: Gamma Radiation Induced Electrical Response of PbZrTiO₃ Varactor		
8.1	Introduction	101
8.2	Pt Electrode Patterning on PbZrTiO ₃ /SrRuO ₃ Films	103
8.3	Capacitance-Voltage Measurement of PZT Varactor	104
8.4	Gamma Irradiation Effect on Dielectric Response of Pt/PZT Varactor	107
	8.4.1 Hysteresis C-V Measurement	113
8.5	Radiation Effects on Device Tunability	115
8.6	Leakage Current Measurements	116
8.7	Conclusions	118
Chapter 9: Conclusion and Future Scope of Work		
9.1	Conclusion	119
9.2	Future Scope of Work	121
References		123

